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04/23/98

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventor : Kaichiro NAKANO, et al.
Serial No. : 09/036,219
Filed : March 6, 1998
Title : CHEMICALLY AMPLIFIED RESIST LARGE IN
TRANSPARENCY AND SENSITIVITY TO EXPOSURE
LIGHT LESS THAN 248 NANOMETER WAVELENGTH AND
PROCESS OF FORMING MASK

April 23, 1998

Assistant Commissioner for Patents
Washington, D.C. 20231

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In order to comply with discretionary rules 37 CFR 1.97 and 1.98, attached hereto is a copy of Form PTO-1449 and copies of the documents listed thereon. These documents contain information which the Examiner may consider to be important in deciding whether to issue a patent in the instant application.

As this Statement is being filed prior to issuance of a first Office Action, no fee is due.

As two of these documents are written in a language other than English, English language abstracts are annexed thereto explaining their relevancy in accordance with 37 CFR §1.98(a)(3).

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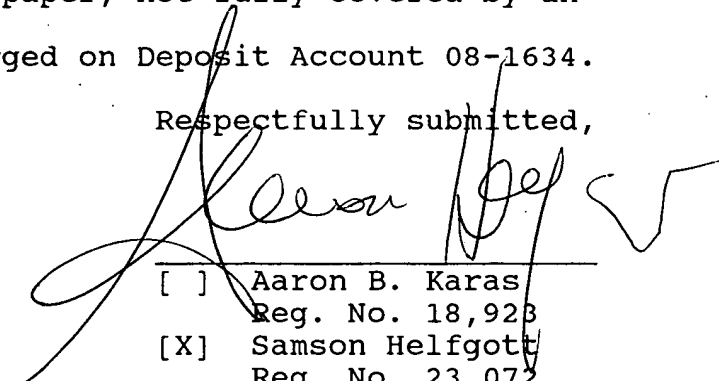
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Early and favorable consideration is respectfully solicited.

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Respectfully submitted,



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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

JC541 U.S. PTO

09/036219



In re the Application of: Kaichiro NAKANO

Filed : Concurrently herewith

For : CHEMICALLY AMPLIFIED RESIST LARGE IN TRANSPARENCY AND
SENSITIVITY TO EXPOSURE LIGHT LESS THAN 248 NANOMETER
WAVELENGTH AND PROCESS OF FORMING MASK

Serial No.: Concurrently herewith

Hon. Commissioner of Patents
and Trademarks
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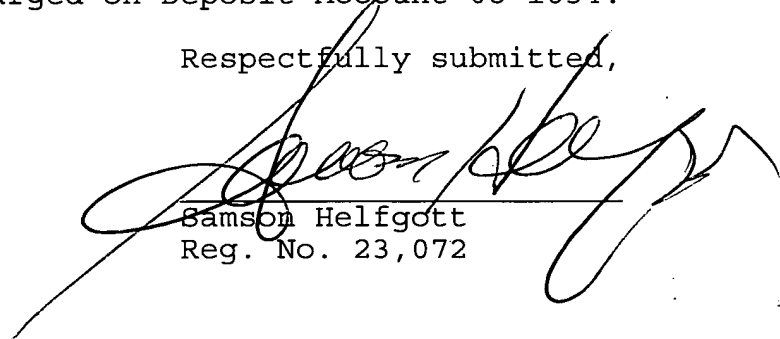
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